



## Giant Ambipolar Rashba Effect in the Semiconductor BiTeI

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We observe a giant spin-orbit splitting in the bulk and surface states of the noncentrosymmetric semiconductor BiTeI. We show that the Fermi level can be placed in the valence or in the conduction band by controlling the surface termination. In both cases, it intersects spin-polarized bands, in the corresponding surface depletion and accumulation layers. The momentum splitting of these bands is not affected by adsorbate-induced changes in the surface potential. These findings demonstrate that two properties crucial for enabling semiconductor-based spin electronics—a large, robust spin splitting and ambipolar conduction—are present in this material.

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The relativistic spin-orbit interaction (SOI) lifts the usual Kramers spin degeneracy in electron systems that lack inversion symmetry. It lies at the origin of many subtle and interesting effects in the electronic structure of materials such as the emergence of topological insulators, a new quantum state of matter. In the bulk of materials with noncentrosymmetric structures, such as the zinc blende and wurzite structures, it gives rise to the Dresselhaus [1] and Rashba [2] effects. An analogous effect, the Rashba-Bychkov effect, describes the lifting of the spin degeneracy at surfaces and at asymmetric interfaces, where inversion symmetry is also broken [3]. The SOI is a general phenomenon, but it is especially relevant in solids containing high-*Z* elements because of their large atomic spin-orbit parameter. The characteristic splitting in energy and momentum was first directly observed by angle-resolved photoelectron spectroscopy (ARPES) on the Au(111) surface [4]. The predicted polarization of the electronic states was confirmed by spin-polarized ARPES [5,6], and the Rashba scenario has been extended to other surfaces and interfaces [7–15].

The vision of an all-electric control of spin transport in new device concepts explains the strong current interest for materials with large Rashba or Dresselhaus effects. Future devices operating at room temperature will require a large separation between the spin-polarized bands and the ability to tune the position of the chemical potential over a broad energy range. Whereas the former have been reported in surface alloys with high-*Z* elements such as Pb or Bi, only limited tunability has been achieved so far.

BiTeI is a noncentrosymmetric semiconductor for which theory predicts a large bulk Rashba effect, and the emergence of a topological insulating phase under pressure [16]. Ishizaka *et al.* [17] used spin-resolved ARPES to

reveal spin-polarized states with a large momentum splitting. They assigned them to a quantum-well state (QWS) confined in the accumulation layer that appears because of band bending in the surface region. This interpretation has been questioned in part by more recent ARPES data and calculations that show the coexistence of surface and bulk bands near the Fermi level [18].

In this Letter, we show that in BiTeI the chemical potential can be moved well into the conduction band or the valence band by controlling the surface termination. Remarkably, a giant spin splitting at the Fermi surface is observed in both cases. First-principles relativistic calculations indicate that both the surface and the bulk bands are split by the SOI. We also prove that the size of the Rashba effect is largely insensitive to changes in the surface potential. Therefore, the splitting has mainly an atomic origin. These results establish BiTeI as a versatile material, characterized by the coexistence of very large ambipolar bulk and surface Rashba effects.

We performed ARPES experiments at the Electronic Structure Factory, beam line 7.0.1 of the Advanced Light Source. The energy and momentum resolution of the hemispherical Scienta R4000 analyzer were 30 meV and 0.1°. High quality single crystals of BiTeI, in the form of platelets, were grown by chemical vapor transport and by the Bridgman technique, and characterized by x-ray diffraction and transport. They showed a metallic conduction due to a small (< 2%) deviation from stoichiometry. The samples were mounted on a He cryostat and cleaved in UHV to expose flat, shiny surfaces.

First-principles electronic structure calculations were performed within the density functional theory framework employing the generalized gradient approximation as implemented in the QUANTUM-ESPRESSO package [19].

Spin-orbit effects were accounted for using the fully relativistic norm-conserving pseudopotentials acting on valence electron wave functions represented in the two-component spinor form [20]. The surface band structures were obtained using a slab model consisting of 39 atomic layers. Since the BiTeI crystal has no inversion symmetry, the surfaces of the slab are necessarily different. The slab model considered here includes two unpassivated experimentally relevant terminations (Te and I). The surface bands at the two different surfaces were disentangled by projecting the Kohn-Sham wave functions onto atomic wave functions at the surface layer. The bulk and the slab band structures were aligned by matching the potential in the middle of the slab with the bulk potential.

BiTeI has a trigonal layered structure, with Bi, Te, and I planes alternating along the  $c$  axis. The Bi and Te planes are covalently bonded to form a positively charged  $(\text{BiTe})^+$  bilayer. The ionic coupling between the bilayer and the adjacent  $\text{I}^-$  plane defines the natural cleavage plane [21]. The topmost layer—Te or I—is identified by the relative intensities of the Te and I  $4d$  core levels, as in Fig. 1(a). Ideally, due to the lack of inversion symmetry, the surface termination is uniquely determined by the direction of the  $c$  axis. However, repeated cleaves of the same crystal randomly expose both terminations due to the occurrence of stacking faults, which also explains the observation of sixfold symmetry in the Laue patterns (not shown). We have measured “pure” surfaces and also “mixed” surfaces that presented areas with both terminations [22]. Data for the former are illustrated in Fig. 1. The surface charges—positive for Te, negative for I—induce

band bending in opposite directions for the two terminations. The Fermi level lies into either the conduction or the valence band, giving rise to a charge accumulation or, respectively, depletion layer. This is schematically illustrated in Fig. 1(b) and 1(c) and substantiated by the ARPES data. It should be noted that our density functional theory calculations reproduce qualitatively the observed band bending. The surface bands of the Te(I)-terminated surface appear below (above) the bulk conduction (valence) bands [Fig. 1(e) and 1(g)].

Figure 1(d) illustrates the ARPES dispersion of the Te-terminated surface, measured along the  $\overline{\Gamma K}$  high-symmetry direction ( $\overline{\Gamma K} = 0.96 \text{ \AA}^{-1}$ ) of the Brillouin zone. The most prominent feature is the split parabolic band ( $\text{SS}_{\text{Te}}$ ) straddling the Fermi level  $E_F$ . The two subbands have minima at  $-0.32 \text{ eV}$  and are offset by  $\pm 0.055 \text{ \AA}^{-1}$  around  $\overline{\Gamma}$ . This is consistent with previous data, and with a Rashba interaction 1 order of magnitude stronger than for the Au (111) benchmark case [17]. This feature is well reproduced in the first-principles band structure of Fig. 1(e). It shows that the spin-split state is localized in the topmost bilayer, and partially overlaps with conduction band states that exhibit a smaller momentum offset. The bulk signal is too weak to be identified in Fig. 1(d), but it can be discerned between  $\text{SS}_{\text{Te}}$  and  $E_F$  at closer inspection [22]. The projected bulk valence band exhibits gaps supporting other surface states. These states exhibit an even larger splitting. Their spin polarization has non negligible radial and out-of-plane components [22], at variance with the simple Rashba scenario, and similar to recent observations on topological insulators [23]. The complex manifold cannot

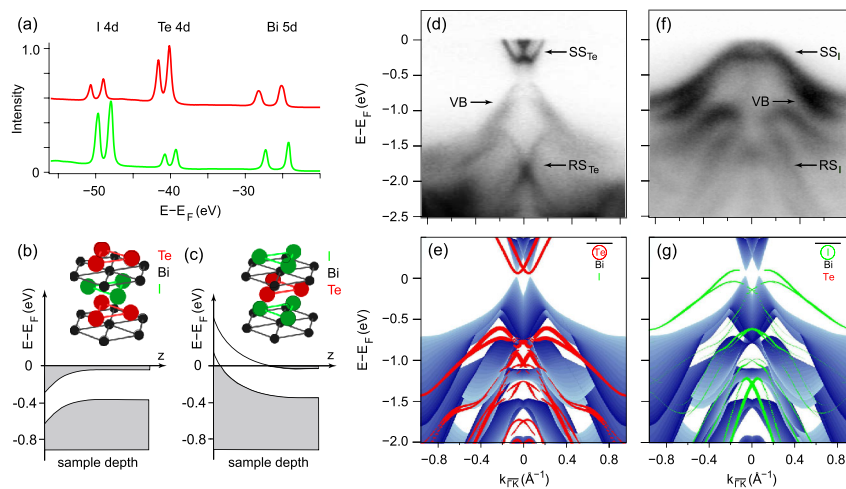


FIG. 1 (color online). (a) I  $4d$ , Te  $4d$ , and Bi  $5d$  core level spectra measured at  $h\nu = 120 \text{ eV}$  on Te- (red, top) and I-terminated (green, bottom) surfaces. (b), (c) Schemes of surface band bending for the two surface terminations. The thickness of the accumulation layer was estimated to be  $\sim 3 \text{ nm}$  in Ref. [17]. (d) ARPES dispersion along the  $\overline{\Gamma K}$  direction measured at  $93 \text{ eV}$  and  $T = 40 \text{ K}$ , for a Te-terminated surface, compared to (e) the projected slab band structure calculated from first principles. The size of the red (grey) symbols is proportional to the magnitude of projection onto the surface Te atoms indicated in the inset. The continuum of bulk states is shown in blue. (f), (g) Corresponding plots for the I-terminated surface. The size of the green (grey) symbols in (g) is proportional to the contribution of the surface I atoms indicated in the inset. In (e) and (g) only projection amplitudes larger than 0.1 are shown.

be easily disentangled in the ARPES map, which shows a prominent state, labeled  $RS_{Te}$ , symmetrically split around  $\bar{\Gamma}$ . The maxima of  $RS_{Te}$  are at  $\pm 0.2 \text{ \AA}^{-1}$  and  $-1.3 \text{ eV}$ , corresponding to a very large and previously unnoticed momentum splitting. The bulk valence band (VB), with a maximum  $0.37 \text{ eV}$  below the bottom of  $SS_{Te}$  also exhibits a large spin-orbit splitting, reproduced by the calculation.

The picture from the I-terminated surface [Figs. 1(f) and 1(g)] is quite different. The electron pockets around  $\bar{\Gamma}$  are replaced by hole pockets from a spin-split state ( $SS_I$ ) with a strong projection on the surface I atoms. The momentum offset is again quite large, of the order of  $\pm 0.2 \text{ \AA}^{-1}$ . A precise determination is difficult because the top of the band lies above  $E_F$ . The top of VB is also located above  $E_F$ . There is a complete change from electron to hole carriers with respect to Fig. 1(d), which demonstrates ambipolar conduction in BiTeI. The total change in band bending between the Te- and I-terminated surfaces, estimated from core level spectra [22], is  $\Delta E_{BB} = 0.9 \text{ eV}$ , to be compared with the estimated energy gap  $\Delta E_g \sim 0.38 \text{ eV}$  [17]. Additional features ( $RS_I$ ) symmetrically split around  $\bar{\Gamma}$ , can again be identified at higher energy in the ARPES map.

We stress the importance of the ambipolar nature of the low-energy states in view of possible applications. Achieving control of the Fermi level position in Rashba systems or topological insulators has proved a challenging task. Previous strategies based on surface doping by chemisorbed species, or on alloying, have obvious drawbacks. The former faces the problem of chemical stability, the latter that of disorder leading to a reduced mobility. By contrast, switching between electron and hole conduction is achieved in BiTeI without modifying the ideal crystal structure or the stoichiometry.

The assignment of the spectral features of Fig. 1 to surface or bulk states is further supported by the data shown in Fig. 2(a). It illustrates the photoelectron intensity measured at near-normal emission from a Te-terminated surface as a function of  $k_z$ , the wave vector along the  $c$  axis.  $SS_{Te}$  exhibits an intensity modulation but no dispersion, as expected for true surface states. By contrast, state VB exhibits a  $\sim 0.7 \text{ eV}$  dispersion along  $\bar{\Gamma}A$ , consistent with its bulk character, and well reproduced by the calculation (dashed line). This is confirmed by constant energy maps (CEM) of these states. The CEM measured at  $E_F$  for  $SS_{Te}$  [Fig. 2(b)] has two concentric contours typical of the Rashba scenario. The external contour, warped by the interaction with the lattice potential, has a sixfold symmetry, as required by time-reversal symmetry for a surface state [24]. In the CEM measured at the crossing point of  $RS_{Te}$  [Fig. 2(d)], the inner contour has collapsed to a point at  $\bar{\Gamma}$ . The outer contour again exhibits a sixfold symmetry. Interestingly, it is not closed around  $\bar{\Gamma}$ , but it is broken into 6 disconnected pockets aligned along the 6 equivalent  $\bar{\Gamma}M$  directions. This can be seen as the limit of strong warping,

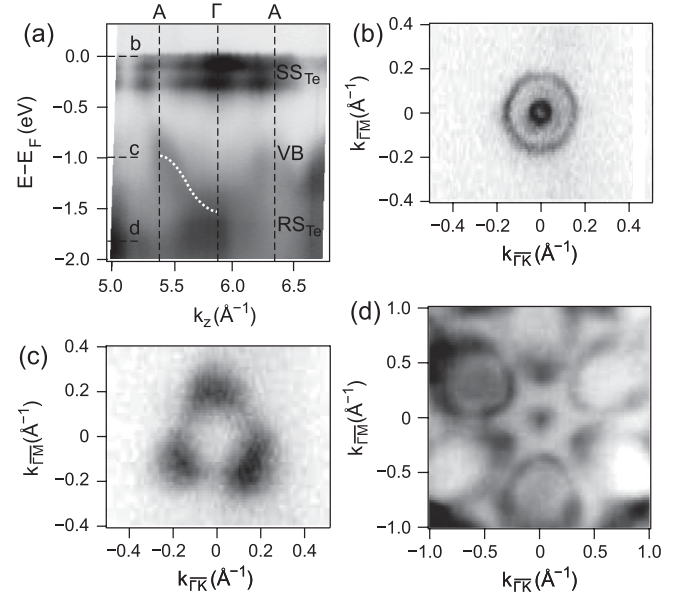


FIG. 2. (a) ARPES intensity from a Te-terminated surface, measured at  $\sim 0.3^\circ$  off normal emission, in a photon energy scan between 84 and 162 eV, plotted as a function of  $k_z$ , the wave vector along the  $c$  axis. Both the upper and the lower branch of  $SS_{Te}$  are visible. The white dashed curve is the calculated dispersion of the corresponding bulk valence state. (b)–(d) Constant energy contours measured at the energies marked by the corresponding horizontal lines in panel (a).

reflecting a large in-plane asymmetry of the surface potential [25]. Conversely, the CEM through VB [Fig. 2(c)] shows a single threefold contour. This symmetry reduction is not due to partial extinction of a sixfold contour induced by ARPES matrix elements, because the pattern remained locked to the crystallographic directions when the crystal was rotated around the surface normal. Therefore, the threefold pattern of VB reflects the threefold symmetry of the bulk potential, and confirms the bulk character of this state [22].

We now turn our attention to the origin of the very large Rashba splitting. Competing models beyond the standard Rashba scenario have been proposed. They alternatively stress atomic contributions [26], the in-plane anisotropy of the surface potential [27], the asymmetry of the wave functions [28], or the local orbital angular momentum [29]. A bulk origin has been invoked for BiTeI [17], but this conflicts with the surface nature of the relevant states.

In the standard Rashba scenario, the size of the splitting is controlled by the gradient of the surface potential, and this prediction was found to be consistent with the properties of QWS formed in an accumulation layer at the surface of the topological insulators  $Bi_2Se_3$  [30]. In order to test this hypothesis for BiTeI, we have changed, in a controlled way, the surface band bending, and hence the gradient of the potential in the surface region. This was achieved by depositing increasing amounts of potassium on a Te-terminated surface. Adsorbed  $K$  atoms donate

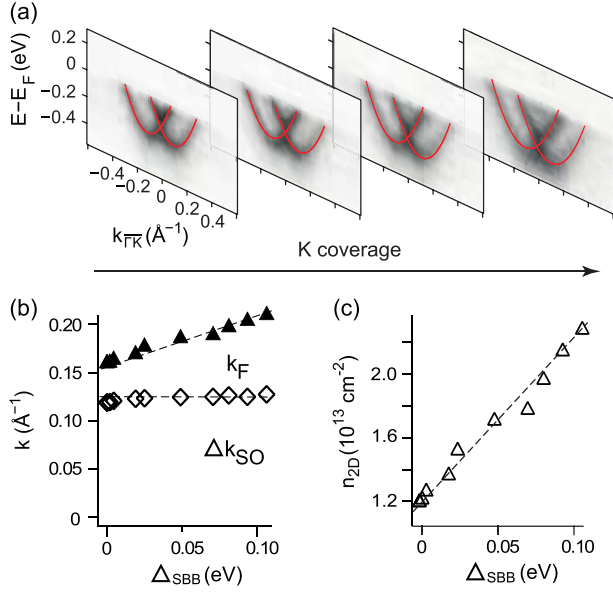


FIG. 3 (color online). (a) Evolution of the spin-split  $SS_{Te}$  surface state band as a function of  $K$  coverage. The two parabolas are the result of a fit to the band dispersion along  $\Gamma\bar{K}$ . (b) The Fermi wave vector  $k_F$  of the outer branch (solid symbols) and the Rashba splitting  $\Delta k_{SO}$  (empty symbols) are plotted as a function of the measured change in surface band bending  $\Delta SBB$ . (c) The corresponding surface electron density.

electrons to the conduction band, leaving a positively charged surface layer which enhances the downward surface band bending. Figure 3(a) illustrates the evolution of  $SS_{Te}$  as a function of  $K$  coverage. Movies of complete  $K$  dosing experiments for both Te- and I-terminated surfaces are available in [22].

As expected,  $SS_{Te}$  and all core levels [22] shift to lower energies, following the change in band bending. The total shift at saturation  $K$  coverage is 0.12 eV, bringing the bottom of  $SS_{Te}$  0.44 eV below  $E_F$ . A closer inspection shows that the energy shift of  $SS_{Te}$  is rigid. Figure 3(b) shows the Fermi wave vector  $k_F$  of the outer branch and the momentum offset  $\Delta k_{SO}$ . They were estimated from a parabolic fit of the dispersion, keeping the effective mass unchanged. Within error bars  $\Delta k_{SO}$  remains constant. The bottom of  $SS_{Te}$  gives an upper limit for band bending. Therefore, a  $>40\%$  change in the surface band bending has no measurable effect on the strength of the Rashba effect. The SO-split surface state at the Ir(111) surface covered by graphene was recently found to be similarly insensitive to the surface potential gradient [31]. This experimental observation strongly suggests that other parameters, namely, the atomic spin-orbit parameter of the heavy elements, determine the large spin splitting. Figure 3(c) shows that the surface carrier density, estimated from the area of the electron pockets, varies linearly with the downward shift of the split bands. This is again consistent with a constant  $\Delta k_{SO}$ . By contrast, deviations from linearity have been observed for the QWS at the  $Bi_2Se_3$  surface [30].

In summary, we have shown that large ambipolar bulk and surface Rashba effects coexist in the noncentrosymmetric semiconductor BiTeI. The Fermi level at the surface lies either into the valence or the conduction band, depending on the nature of the topmost layer. Achieving ambipolar conduction in a semiconductor with a large Rashba splitting is an important step toward practical applications. In our bulk crystals, the surface termination was randomly chosen by cleavage due to stacking faults, but a definite improvement is possible in thin film samples. Molecular beam epitaxy and chemical vapor deposition—a technique compatible with large-scale thin film production—can in fact be exploited to gain control on the nature of the topmost layer. It is therefore realistic to consider that regions with opposite band bending—a “Rashba  $p$ - $n$  junction”—could be patterned on a substrate, opening new perspectives for the manipulation of spin-polarized states.

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